

# A Novel MoSe<sub>2</sub>–Reduced Graphene Oxide/Polyimide Composite Film for Applications in Electrocatalysis and Photoelectrocatalysis Hydrogen Evolution

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Promising catalytic activity of MoSe<sub>2</sub> in the hydrogen evolution reaction (HER) is synthesized on a new reduced graphene oxide/polyimide (rGO/PI) substrate by a simple electrochemical method. The MoSe<sub>2</sub> nanoparticles have excellent photo-responsive properties; the potential difference could reach 0.45 V with the photo-responsive time just 0.6 s. Furthermore, MoSe<sub>2</sub> thin film exhibits superior catalytic activity in the hydrogen evolution reaction (HER). It has a greater cathode current at more positive potential compared to other MoSe<sub>2</sub> and MoS<sub>2</sub>, and the efficiency of H<sub>2</sub> evolution is strongly influenced by illumination; this suggests that MoSe<sub>2</sub> composite film has good photoelectrocatalysis properties for hydrogen evolution. Besides, both dark and illumination MoSe<sub>2</sub> films exhibit extremely high stability in acidic solution as the HER catalytic activity shows no degradation after 100 cycles for two hours. All results indicate that MoSe<sub>2</sub>–rGO/PI composite film has potential to be a better catalyst for HER.

## 1. Introduction

Hydrogen production from water splitting has attracted growing attention for fulfilling the global energy demand and for tackling the environmental issues.<sup>[1,2]</sup> While Pt and its alloys are the best catalysts for the hydrogen evolution reaction (HER) in acidic media, but their low abundance and high cost prevent the massive deployment of these materials for hydrogen production. Therefore, it is necessary to investigate other types materials that can mimic the performance of Pt for the HER.<sup>[3–5]</sup> MoSe<sub>2</sub> is a semiconductor whose structure is similar to graphene, it is endowed with a band gap of 1.7–1.9 eV and good semiconductor properties.<sup>[6–8]</sup> To date, several MoSe<sub>2</sub> nanostructures were published that showed an excellent HER performance. However, some of these approaches usually need either high temperature or high pressure, long reaction time or special devices, while some require toxic reagents.<sup>[9–12]</sup> As

an alternative approach, electrochemical deposition can commendably control film ingredients, thickness, purity and uniformity; it is a technique with many advantages including simple equipment, considerable low temperature, controllable conditions and environmentally friendly.<sup>[13–17]</sup>

Although the HER performance of MoSe<sub>2</sub> has been studied, the semiconductor properties are underutilized. MoSe<sub>2</sub> has good photoelectric property,<sup>[18]</sup> what if the HER performance combines with photoelectric property, the MoSe<sub>2</sub> will be utilized fully. In our work, MoSe<sub>2</sub> is fabricated on a new rGO/PI composite substrate by electrochemical deposition. rGO/PI film as working electrode is chosen by its advantages; such as flexible, light, excellent mechanical property,

thermal stability, dimensional stability and so on. Besides, the rGO/PI membrane can withstand heat and cold over a wide temperature range of –200 to 300 °C.<sup>[19–21]</sup> Photoelectrochemical water splitting is emerging as a promising clean technique for the synthesis of H<sub>2</sub> gas, which could be used as a clean and renewable energy source. By a series of study, it is found that MoSe<sub>2</sub> exhibits superior electrocatalytic and photoelectrocatalytic activity in the HER, because the deposition can generate very high photocurrent for hydrogen evolution under irradiation. Besides, it has a greater cathode current at more positive potential comparing with other materials. The photoelectric property also exhibits excellent reversibility and stability. All results indicate that the p-type MoSe<sub>2</sub>–rGO/PI composite film is promising to be used for solar-driven hydrogen evolution.

## 2. Result and Discussion

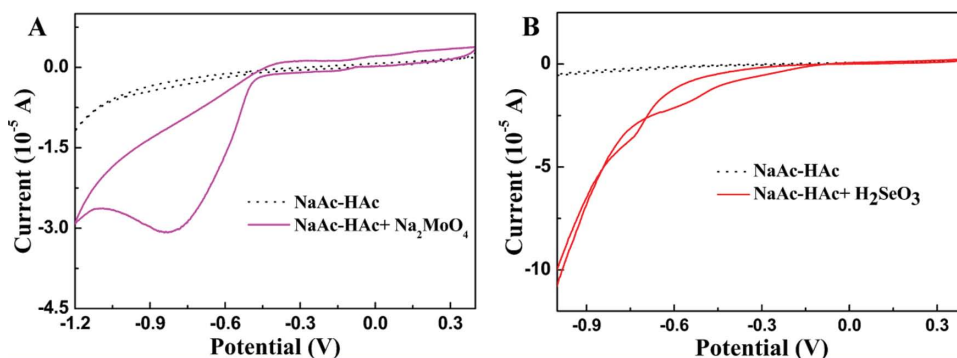
### 2.1. Electrochemical Characteristics

Cyclic voltammetry is the best tool to investigate electrochemical reaction in precursor solutions. Figure 1A shows the CVs of Na<sub>2</sub>MoO<sub>4</sub> measured at the rGO/PI membrane electrode, the cathodic current began to increase gradually at –0.45 V, and an obvious peak was obtained at –0.8V, it can be ascribed to the reduction of MoO<sub>4</sub><sup>2–</sup>. The electrochemical behavior of Se was also studied, the reduction potential is between –0.4 and

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**Figure 1.** CV measured on the rGO/PI membrane electrode corresponding to A) 0.2 M NaAc-HAc buffered solution (PH = 3.6) and 5 mM  $\text{Na}_2\text{MoO}_4$ ; B) 0.2 M NaAc-HAc buffered solution and 5 mM  $\text{H}_2\text{SeO}_3$ .

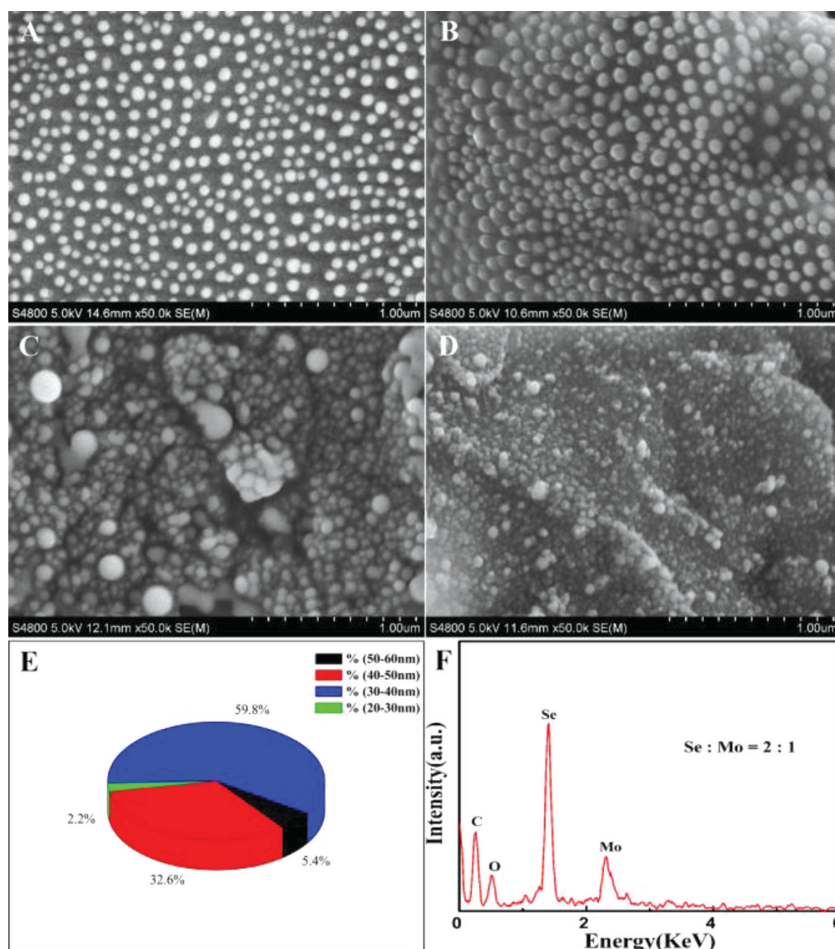
−0.7 V, as shown in Figure 1B. Besides, in order to optimize the deposition conditions for  $\text{MoSe}_2$ , the effect of deposition potentials and concentrations were investigated. At last the electrodeposition conditions for  $\text{MoSe}_2$  are 0.04 M  $\text{Na}_2\text{MoO}_4$ , 0.02 M  $\text{H}_2\text{SeO}_3$ , and 0.2 M NaAc–HAc buffered solution (PH = 3.6) at −0.6 V.

(012) and (104). The crystal plane (004) can be indexed to the crystal phase of  $\text{MoSe}_2$  (JCPDS: 29–0914), and the others were ascribed to the phase (JCPDS: 20–0757). Besides, the XRD result also illustrates that the  $\text{MoSe}_2$  is a polycrystalline material. The Raman spectrum of  $\text{MoSe}_2$  was shown in Figure 3E, the  $\text{A}_{1g}$  was out-of-plane mode and  $\text{E}_{2g}^1$  was in-plane mode

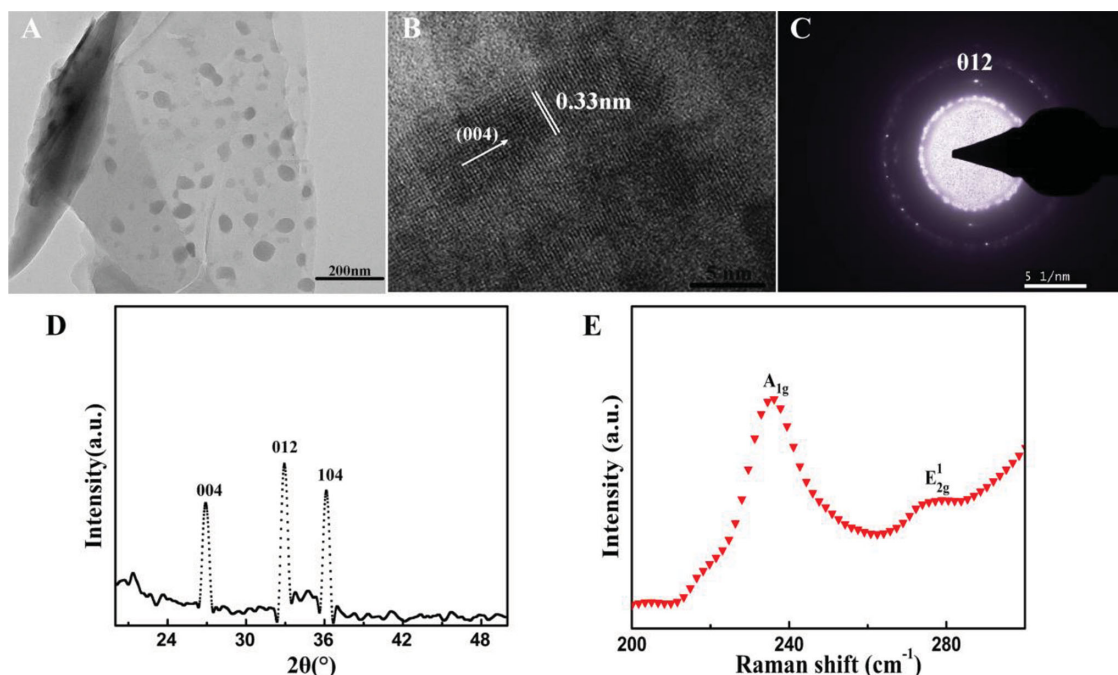
## 2.2. Structure and Morphology

The morphologies of the obtained samples were investigated in detail by SEM. Figure 2A–D show the SEM images of samples obtained at 5, 10, 20, and 30 min. The morphologies of products are all nanoparticles, which indicated that the morphology of product would not change with different time, it just increased the amount. The diameters of these  $\text{MoSe}_2$  particles are estimated to be approximately 30–50 nm because the size of 30–40 and 40–50 nm particles are the great mass of them corresponding to 59.8% and 32.6% respectively, as is shown in Figure 2E; the 20–30 and 50–60 nm particles were just few. Figure 2F shows the ratio of  $\text{MoSe}_2$ , it was calculated to be 1:2, in agreement with the stoichiometric ratio. Besides, the C and O peaks were ascribed to the substrate rGO/PI.

The TEM image in Figure 3A shows the as-formed  $\text{MoSe}_2$  is nanoparticles with various sizes, and the size range is according with the statistics in Figure 2E. The HRTEM image (Figure 3B) reveals clearly lattice fringe of  $\text{MoSe}_2$ , and the lattice stripe spacing along the growth axis is 0.33 nm; corresponding to the interplanar distance of (004) diffraction crystal. Figure 3C shows that  $\text{MoSe}_2$  is a polycrystalline nature. To confirm the crystal-line structure of the  $\text{MoSe}_2$  film, the sample was researched by XRD, as shown Figure 3D. There were three obvious strong peaks, all recorded diffraction peaks could be easily indicated to the crystal planes of (004)



**Figure 2.** SEM images of  $\text{MoSe}_2$  nanoparticles on substrate rGO/PI: A–D) SEM images of  $\text{MoSe}_2$  with electrodeposition 5, 10, 20, and 30 min; E) the distribution of  $\text{MoSe}_2$  nanoparticles size; F) EDS of  $\text{MoSe}_2$ .



**Figure 3.** Structure of MoSe<sub>2</sub>. A) TEM image of MoSe<sub>2</sub> nanoparticles; B,C) HRTEM and selected area electron diffraction images; D,E) XRD pattern and Raman spectrum.

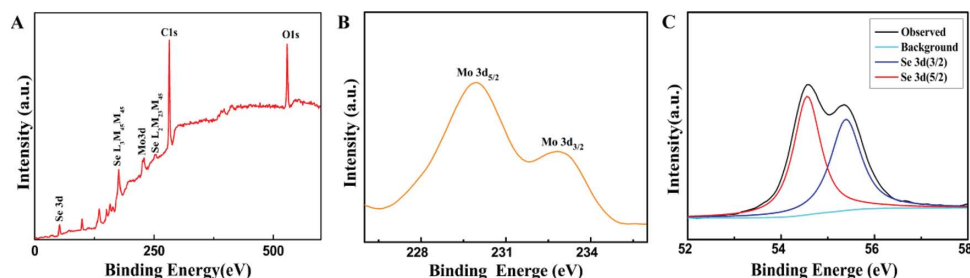
with the former being at a higher frequency than the latter. The nanoparticles showed characteristic A<sub>1g</sub> and E<sub>2g</sub><sup>1</sup> Raman modes located at 236 cm<sup>-1</sup> and 278 cm<sup>-1</sup>, respectively.

Chemical compositions of these materials were further investigated by X-ray photoelectron spectroscopy (XPS) analysis (Figure 4). The binding energies of Mo 3d<sub>5/2</sub> and Mo 3d<sub>3/2</sub> were 229 and 232 eV in Figure 4B, respectively; revealing the +4 oxidation chemical state of Mo.<sup>[22–24]</sup> Se 3d XPS analysis showed two peaks for 3d<sub>5/2</sub> at 54.5 eV and 3d<sub>3/2</sub> at 55.4 eV, as shown in Figure 4C; indicating the oxidation state of –2 for Se in material.<sup>[25,26]</sup> Quantitative elemental analysis from XPS peaks integration showed 34.2% Mo and 65.8% Se; which confirms that deposition ratio of Mo: Se is about 1 : 2, it confirmed each other with EDS result. All the conclusions demonstrate the deposition on rGO/PI is MoSe<sub>2</sub>.

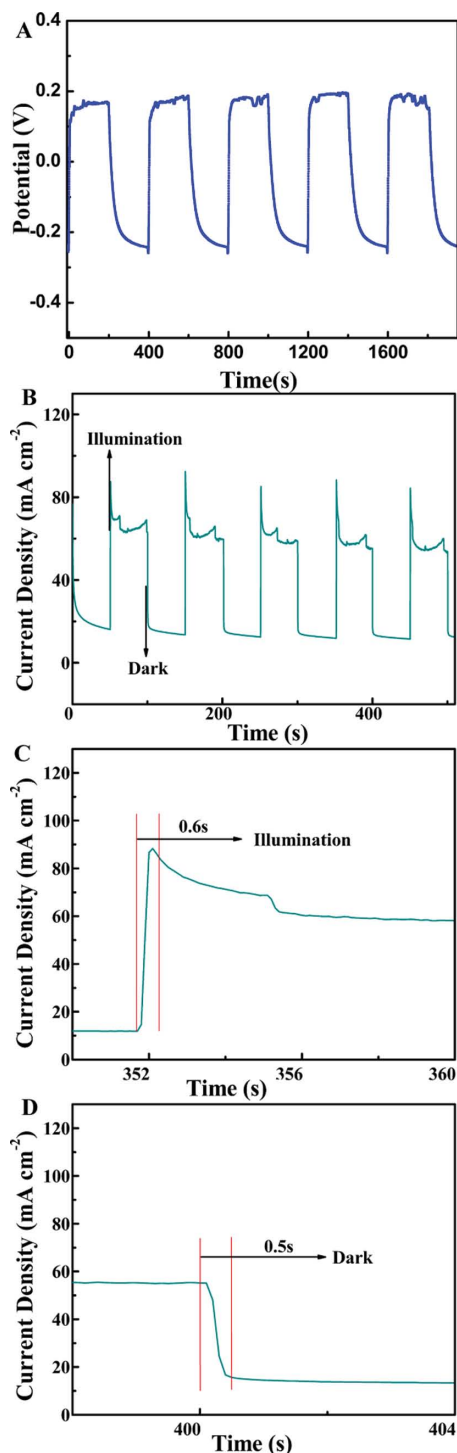
### 2.3. Photoelectric Property

In order to study the photoelectric property of MoSe<sub>2</sub>, OCP and amperometric methods (*i*–*t*) were performed in 0.2 M NaAc-HAc buffered solution (PH = 3.6) during sequential

darkness and illumination. OCP was measured with the xenon lamp time interval 200 s that turned on and turned off as shown in Figure 5A. Remarkable photoelectric response was observed from the on/off light cycles. V<sub>ocp</sub> stayed at a lower level with light off and increased quickly under irradiation, which indicated MoSe<sub>2</sub> nanoparticles is p-type conductive material, and the potential difference can reach 0.45 V. The *i*–*t* study of MoSe<sub>2</sub> was performed with on–off irradiation cycles interval 50 s at –0.3 V. As seen in Figure 5B, the current difference induced by irradiation is 80 uA/cm<sup>2</sup> for MoSe<sub>2</sub>. Figure 5C–D show the photo-responsive characteristics of MoSe<sub>2</sub>. When the light was turned on, the photocurrent increased rapidly in 0.6 s. A spike value of photocurrent can be observed because of the transient effect in power excitation, whereafter the photocurrent achieved a steady value rapidly; after switching off the light, the photocurrent reduced quickly in 0.5 s and recovered to the original current value; these were accorded with the OCP result. The change regular of photoelectric phenomenon for MoSe<sub>2</sub> is because the electron of valence band will jump into conduction band as soon as photon energy is greater than or equal to the band gap



**Figure 4.** XPS core level spectra of MoSe<sub>2</sub>: A) Survey spectra; B) High resolution Mo 3d spectra; C) High resolution Se 3d spectra.



**Figure 5.** A) OCP vs time of MoSe<sub>2</sub>. B) *I*-*V* curves of the MoSe<sub>2</sub> measured in the dark and under illumination; C, D) photocurrent-time curves of the photosensitiveness.

energy of the semiconductor under illuminated, but p-type semiconductor compound has more electro holes than electrons, at this moment, electro holes would act as conductive task.<sup>[27]</sup> After scores of cycles, the photocurrent can be still changed distinctly with repeatedly turning the xenon lamp on

and off; demonstrating that MoSe<sub>2</sub> composite membrane has excellent reversibility and stability.

## 2.4. Electrocatalysis H<sub>2</sub> Evolution Activity

To evaluate the catalytic activity of MoSe<sub>2</sub> over substrate rGO/PI, the catalytic activity for H<sub>2</sub> was examined in 0.5 M H<sub>2</sub>SO<sub>4</sub> with the scan rate of 50 mV s<sup>-1</sup>. Linear sweep voltammetry (LSV) was used to determine the kinetic activity of the films. **Figure 6A** shows the results of LSV about bare substrate and MoSe<sub>2</sub> electrodeposited for 5 min. From the polarization measurements, the current density of substrate rGO/PI almost remain unchanged in the potential range; but the cathodic current of MoSe<sub>2</sub> began to increase gradually at -0.25 V versus SCE and had an obvious increase at -0.45 V, illustrating MoSe<sub>2</sub> displays excellent responsive for H<sup>+</sup>. **Figure 6B** shows polarization curves of the MoSe<sub>2</sub> with deposition time increasing from 5 to 40 min. As the deposition time increases during 5 and 35 min, the overpotential decreases. However, when time extended to 40 min, the catalytic activity almost kept stable even reduced. So the best electrodeposition time is 35 min for MoSe<sub>2</sub>. The MoSe<sub>2</sub> (35 min) film displays an onset potential for hydrogen evolution with high catalytic current densities of 3.1 mA/cm<sup>2</sup> at -0.3 V, and the maximum current density of 29 mA/cm<sup>2</sup> was obtained at -0.8 V. Compared to other MoSe<sub>2</sub> and MoS<sub>2</sub> in these literatures,<sup>[9,10,28–30]</sup> It is found the MoSe<sub>2</sub> (35 min) has even more current densities at low potentials, as **Table 1**. The potentials in Table 1 are corresponded to normal hydrogen electrode potentials. The potential was converted to the NHE electrode by

$$E(\text{NHE}) = E(\text{Hg}/\text{HgCl}_2) + 0.251 \text{ V}$$

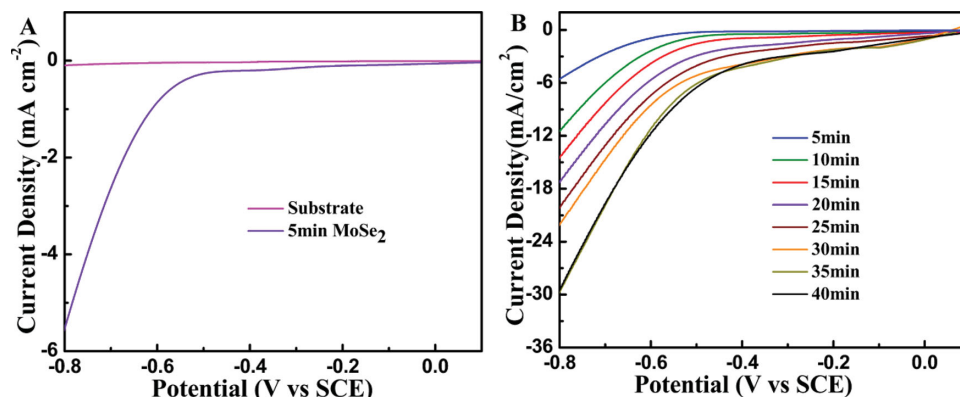
The  $E(\text{Hg}/\text{HgCl}_2)$  is 0.251 V at 15 °C.

## 2.5. Photoelectrocatalysis H<sub>2</sub> Evolution Activity

The photoelectric hydrogen evolution of MoSe<sub>2</sub> was investigated under xenon lamp; all measure process was under illumination. The investigation conditions are the same as the previous hydrogen evolution. The catalytic current increased obviously by the light enhanced at the same potential from **Figure 7**. For example, the cathode current 10.9 mA cm<sup>-2</sup> of -0.6 V increased to 14.5 mA cm<sup>-2</sup> with 400 W illumination, illustrating irradiation could effectively promote HER for MoSe<sub>2</sub>. The unique property of p-type MoSe<sub>2</sub>-rGO/PI composite film makes it promising to be used for solar-driven hydrogen evolution.<sup>[31–33]</sup>

**Figure 8A** shows the photocatalysis principle diagram for HER. MoSe<sub>2</sub> is a p-type semiconductor, the H<sup>+</sup> will capture the electron that valence band jumped into conduction band as soon as the semiconductor is illuminated, so irradiation promote hydrogen evolution for MoSe<sub>2</sub>.<sup>[34–37]</sup> **Figure 8B** is the phenomenon during hydrogen evolution reaction process, the solution belches out a lot of bubbles, it reflects factually the excellent catalytic activity of MoSe<sub>2</sub>.





**Figure 6.** Hydrogen evolution reaction (HER) in 0.5 M H<sub>2</sub>SO<sub>4</sub> at the scan rate of 50 mV s<sup>-1</sup>; A) Polarization curves of MoSe<sub>2</sub> film (5 min) as well as blank rGO/PI substrate showing H<sub>2</sub> evolution; B) polarization curves of the MoSe<sub>2</sub> with increasing deposition time from 5 to 40 min.

## 2.6. The Stability and Tafel Slope

Another important criterion for a good electrocatalyst is high durability. The as-grown catalyst was cycled by taking continuous LSV between -1.0 and 0.1 V for MoSe<sub>2</sub> versus SCE. The polarization curves before and after cycling were recorded with a rate of 50 mV s<sup>-1</sup> about two hours. **Figure 9A,B** show the stability under dark, polarization curves after the 100 cycles diverged from the curve of the first cycle with small increase of cathodic current, as shown in **Figure 8B**. The curves of **Figure 9C,D** were obtained under illumination, the catalyst activities are improved markedly, and along with the increasing of times, the cathodic currents increased a little every other 50 cycles. These results confirmed the extremely high stability of MoSe<sub>2</sub> whether dark or irradiation. So good stability of MoSe<sub>2</sub>-rGO/PI composite membrane demonstrates further it is a good material for solar-driven hydrogen evolution.

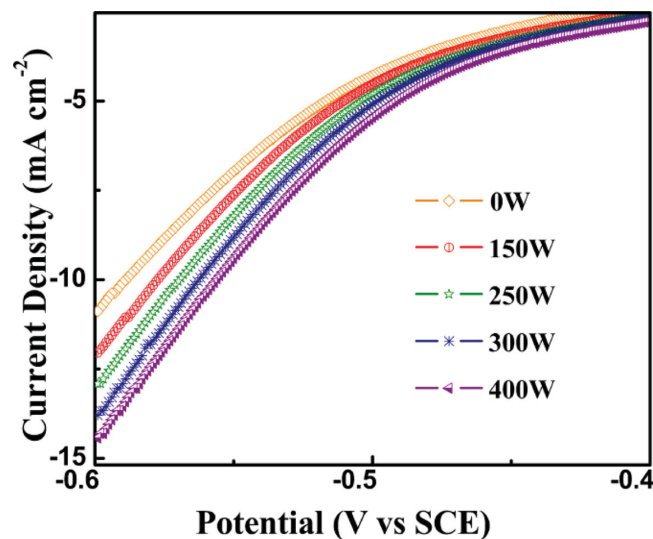
The stability of MoSe<sub>2</sub>-rGO/PI composite membrane was investigated further with current density vs time curve, the electrode was polarized at a potential V = -0.6 V. As shown in **Figure 10A**. The stability of the cathodic photocurrent seems surprising since it hardly decreased; both in dark and illumination the substrate emerged high stability and sufficient cathodic current density, which is in accord with previous

result, and they are mutual corroboration. The Tafel slope is an inherent property of the catalyst that is determined by the rate-limiting step of the HER. The overpotential  $\eta$  (V) observed during an experiment is given by  $\eta = a + b \log |j|$ ; where  $a$  (mV) is the Tafel constant,  $j$  (mA cm<sup>-2</sup>) is the current density and  $b$  is the Tafel slope. The linear portions of the Tafel plots (**Figure 10B**) were fitted to the Tafel equation yielding Tafel slope of 82 mV per dec. According to the three possible reaction steps that have been suggested for the HER in acidic media;<sup>[38–40]</sup> in this work, it seems that the free energy barrier of the discharge step is reduced to be comparable with that of the following desorption or discharge step, resulting in the slope of 82 mV dec<sup>-1</sup>. A small Tafel slope is desired for practical application of HER catalysts, and the Tafel slopes of MoSe<sub>2</sub> nanoparticles is smaller than other MoSe<sub>2</sub> prepared in these literatures.<sup>[9,41]</sup> The plausible reasons is: 1) the MoSe<sub>2</sub> is prepared electrodeposition, the small nanoparticles are more beneficial to the hydrogen evolution; 2) the new substrate rGO/PI composite membrane possesses more superficial area compared to basal plane. These results indicate the

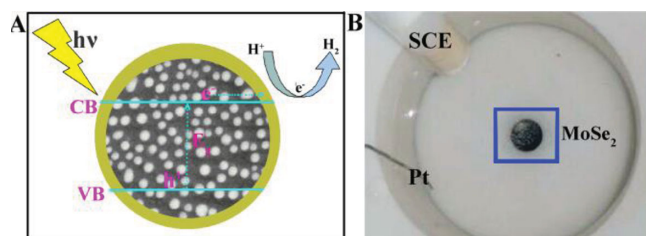
**Table 1.** Comparison the current density at the same potentials based on rGO/PI–MoSe<sub>2</sub> nanoparticles with other hydrogen evolution materials. The potentials correspond to normal hydrogen electrode potentials.

Materials	$J$ (-0.1 V) mA cm <sup>-2</sup>	$J$ (-0.2 V) mA cm <sup>-2</sup>	$J$ (-0.3 V) mA cm <sup>-2</sup>	Ref.
MoS <sub>2</sub>	0.1	0.5	2	[9]
MoSe <sub>2</sub>	0.1	0.8	2	[9]
MoSe <sub>2</sub>	<1	3	15	[10]
MoS <sub>2</sub>	<1	<1	3	[28]
MoS <sub>2</sub> /RGO	<1.5	30	–	[29]
MoS <sub>2</sub>	<1	<1	20	[30]
MoSe <sub>2</sub>	3.6	4.9	7.9	This work

$J$  is the current density.



**Figure 7.** The HER catalytic activity of MoSe<sub>2</sub> composite membrane varied with illumination intensity.



**Figure 8.** A) photocatalysis principle diagram of p-type semiconductor for HER; B) the phenomenon of MoSe<sub>2</sub>-rGO/PI film for hydrogen evolution reaction.

MoSe<sub>2</sub>-rGO/PI composite film is a promising candidate for HER in photoelectrochemical cells.

### 3. Conclusion

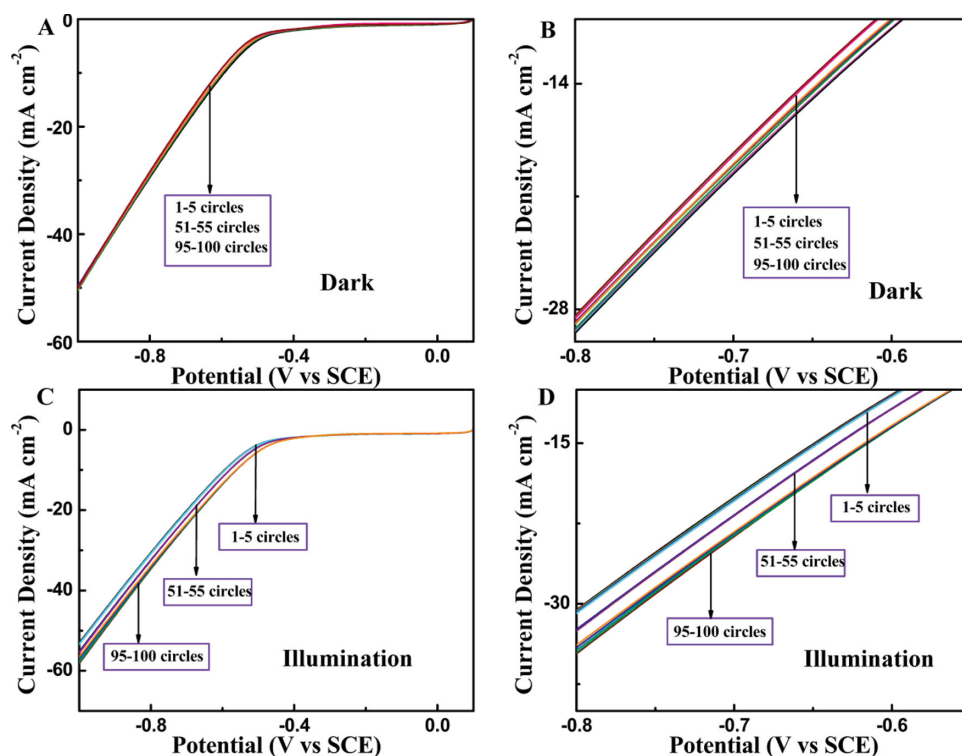
In conclusion, we have first synthesized MoSe<sub>2</sub> nanoparticles on rGO/PI substrate by a simple electrodeposition method. The resulting product exhibited superior photoelectric property and HER activity. Although the MoSe<sub>2</sub> is still a little worse than the best catalytic activity, it has an advantage that greater cathode current appears at more positive potential compared to other MoSe<sub>2</sub> and MoS<sub>2</sub> materials. The hydrogen evolution reaction is combined with irradiation finding that the catalytic activity of MoSe<sub>2</sub> nanoparticles enhanced. Besides, both dark and irradiation MoSe<sub>2</sub> film exhibits extremely high stability in acidic solution, all results point out that the MoSe<sub>2</sub> composite film

has potential to be a better catalyst for HER and solar-driven hydrogen evolution.

### 4. Experimental Section

**Materials and Instruments:** All electrochemical experiments were performed using a CHI 832 Instruments (CH Instrument, USA). The surface morphology was observed through a field-emission scanning electron microscope (FE-SEM) (Hitachi S-4800, Japan). The crystalline structure was determined by X-ray diffraction (XRD) (RigakuD/max-2400) and X-ray photoelectron spectroscopy (XPS) was used to analyze the chemical environment of elements present in MoSe<sub>2</sub>. Transmission electron microscopy (TEM) images, high-resolution transmission electron microscopy (HRTEM) images were taken with an analytical TEM apparatus from FEI Tecnai G<sup>2</sup> F30 TEM. The photo electrochemical properties were investigated by Open-circuit potential measurement (OCP) under a 500 W xenon lamp (CHF-XM-500W, Beijing Trusttech Co. Ltd.).

**Fabrication of the MoSe<sub>2</sub>-rGO/PI Composite Film:** MoSe<sub>2</sub> was carried out at a potential of -0.6 V in a solution containing 0.04 M Na<sub>2</sub>MoO<sub>4</sub>, 0.02 M H<sub>2</sub>SeO<sub>3</sub>, and 0.2 M NaAc-HAc buffered solution on substrate rGO/PI in a conventional three-electrode. Here, the rGO/PI substrate acts as the working electrode with the area of 0.1256 cm<sup>2</sup>; it was synthesized according to previous work,<sup>[42]</sup> the only difference was that 0.0769 g (15 wt%) rGO was added to enhance the conductivity of the material in this work. A Pt wire and a saturated calomel electrode (SCE) were used as counter and reference electrode. These electrodes were connected to a CHI 832 electrochemical workstation. All the chemicals were of analytical grade. All the aqueous solution were made up of water purified by Milli-Q pure water system (Millipore, electrical resistivity 18.2 MΩ cm<sup>-1</sup>).



**Figure 9.** Catalyst stability tests for MoSe<sub>2</sub> with 100 cycles: A,B) in the dark and C,D) under illumination.

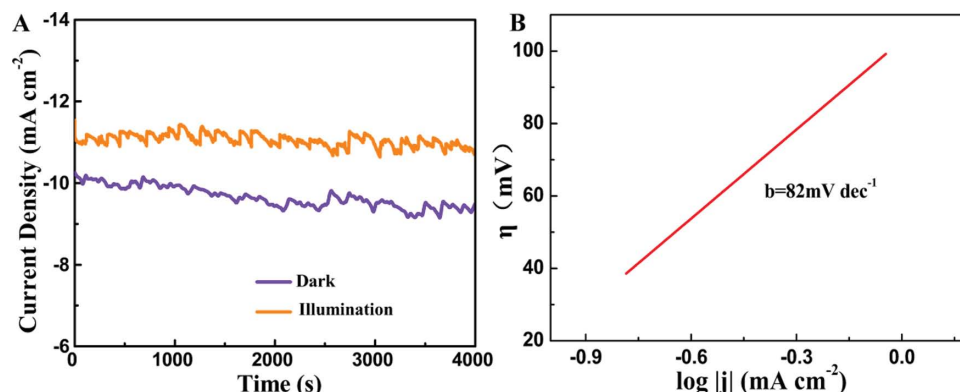


Figure 10. A) Plot of cathodic dark current at  $-0.6$  V vs SCE, B) Tafel plots of  $\text{MoSe}_2\text{-rGO/PI}$  film.

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